



IN THE HAPPED STATES PATENT AND TRADEMARK OFFICE

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In re Application of:

Davis, et al.

Serial No.: 10/665,934

Confirmation No.: 6821

Filed:

September 19, 2003

For: Method Of Controlling Critical
Dimension Microloading Of
Photoresist Trimming Process By

Selective Sidewall Polymer

Deposition

Group Art Unit: 2812

Examiner:

Brook Kebede

MAIL STOP AMENDMENT Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450 CERTIFICATE OF MAILING 37 CFR 1.8

I hereby certify that this correspondence is being deposited on January 6, 2005 with the United States Postal Service as First Class Mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450 Alexandria, VA 22313-1450.

0//06/2005

Date

Signature

Dear Sir:

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The Applicants, and the Agent who signs below on the basis of the information supplied by the inventor and the information in his file, submit herewith patents, publications, or other information of which they are aware, which may be material to the examination of this application and in respect of which there may be a duty to disclose in accordance with 37 CFR § 1.56.

While the information submitted in this Supplemental Information Disclosure Statement may be material pursuant to 37 CFR § 1.56, it is not intended to constitute an

admission that any patent, publication, or other information referred to therein is prior art for this invention unless specifically designated as such.

In accordance with 37 CFR § 1.97, this Supplemental Information Disclosure Statement is not to be construed as a representation that a search has been made or that no other possibly material information as defined under 37 CFR § 1.56(a) exists.

The patents and/or publications submitted herewith are set forth on the attached Form PTO-1449.

The Commissioner is hereby authorized to charge the sum of \$180.00 due under 37 CFR § 1.17(p) pursuant to § 1.97, and any other fee necessary to make this submission timely, to the Deposit Account No. 20-0782/AMAT/7989/LYC.

Respectfully submitted,

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Agent for Applicant(s)

PTO/SB/08a (08-03)

Approved for use through 07/31/2006. OMB 0651-0031
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Substitute for form 1449A/PTO

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(Use as many sheets as necessary)

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Sheet	1	of	3	

Complete if Known					
Application Number	10/665,934				
Filing Date	09/19/2003				
First Named Inventor	Liu, et al.				
Art Unit	2812				
Examiner Name	Unassigned				
Attorney Docket Number	7989/ETCH/SILICON/JB1				

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Examiner Initials *	Cite No. ¹	Document Number Number - Kind Code ² (if known)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pagès, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	
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SUPPLEMENTAL INFORMATION **DISCLOSURE STATEMENT BY APPLICANT**

Complete if Known Application Number 10/665,934 Filing Date 09/19/2003 First Named Inventor Liu et al. Art Unit 2812

(Use as many sheets as necessary)			Examiner Name		Unassigned				
Sheet	2	of 3		Attorn	mey Docket Number		7989/ETCH/SILICON/JB1		
	U.S. PATENT DOCUMENTS								
Examiner Initials *	Cite No.1	Document Number Publication MM-DD-Y			Date Name of Patentee or Applicant of Cited			Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	
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Examiner					Date			.	

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Substitute for form 1449B/PTO Complete if Known Application Number 10/665,934 SUPPLEMENTAL INFORMATION Filing Date 09/19/2003 **DISCLOSURE STATEMENT BY** First Named Inventor Liu et al. **APPLICANT** Art Unit 2812 (Use as many sheets as necessary) Examiner Name Unassigned 7989/ETCH/SILICON/JB1 Attorney Docket Number Sheet of 3

		NON PATENT LITERATURE DOCUMENTS	
Examin er Initials *	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T²
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Signature	Considered	

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